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Tariq Mahmud,^a Javed Iqbal,^a Muhammad Irshad,^a Mark R. J.

Elsegood^b and Vickie McKee^b*

^aInstitute of Chemistry, University of the Punjab, Lahore 54590, Pakistan, and ^bChemistry Department, Loughborough University, Loughborough, Leicestershire LE11 3TU, England

Correspondence e-mail: v.mckee@lboro.ac.uk

Key indicators

Single-crystal X-ray study T = 150 KMean $\sigma(\text{C-C}) = 0.011 \text{ Å}$ R factor = 0.033 wR factor = 0.074Data-to-parameter ratio = 20.2

For details of how these key indicators were automatically derived from the article, see http://iournals.iucr.org/e.

Pentacarbonyl(*N*,*N*-dimethylbenzylamine)-tungsten

The title compound, $[W(C_9H_{13}N)(CO)_5]$, was prepared by irradiation of $W(CO)_6$ in tetrahydrofuran in the presence of N,N-dimethylbenzylamine. The geometry at the W atom is approximately octahedral, with the cis bond angles in the range 86.3 (3)–95.6 (2)°. The bond to the tertiary amine is long [2.371 (5) Å] and, as might be expected, the bond to the trans carbonyl is quite short $[W-C=1.964\ (7)\ Å]$. The remaining W-CO bonds lie in the range 2.033 (6)–2.049 (6) Å. Similar bonding patterns have been observed in related $W(CO)_5$ (amine) complexes,

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Comment

 $(N,N ext{-Dimethylbenzylamine})$ pentacarbonyltungsten was prepared by irradiation of W(CO)₆ in tetrahydrofuran (THF) in the presence of the amine. Presumably, the reaction proceeds via an intermediate THF complex (Aroney $et\ al.$, 1994, and references therein):

$$W(CO)_6 + THF \rightarrow W(CO)_5(THF) + CO$$

 $W(CO)_5(THF) + C_9H_{13}N \rightarrow W(CO)_5(C_9H_{13}N) + THF.$

Although a number of cyclometallated complexes of tungsten with this ligand have been reported previously (van der Schaaf *et al.*, 1993), no carbonyl complex has been structurally characterized. Also, in our hands, no cyclometallated complex was isolated.

The structure of (*N*,*N*-dimethylbenzylamine)penta-carbonyltungsten, (I), is shown in Fig. 1. The geometry at the W atom is approximately octahedral, with the *cis* bond angles in the range 86.3 (3)–95.6 (2) $^{\circ}$. The bond to the tertiary amine is long [2.371 (5) Å] and, as might be expected, the bond to the *trans* carbonyl is quite short [W1–C10 = 1.964 (7) Å]. The remaining W–CO bonds lie in the range 2.033 (6)–

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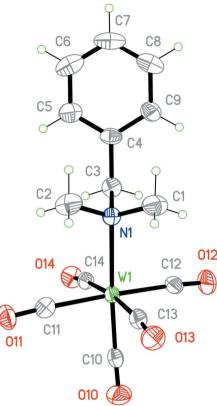


Figure 1
Perspective view of the the complex, with displacement ellipsoids drawn at the 50% probability level.

2.049 (6) Å. Similar bonding patterns have been observed in related $W(CO)_5$ (amine) complexes [see, for example, Long *et al.* (2002) and Moralejo *et al.* (1991)]. There are no obvious π – π or edge-to-face interactions.

Experimental

 $W(CO)_6$ (0.351 g, 1.0 mmol) and N,N-dimethylbenzylamine (0.30 ml, 2.0 mmol) were dissolved in sodium-dried THF (20 ml). The mixture was stirred under N₂ and irradiated with UV light for 4 h, yielding a yellow solution. The progress of the reaction was monitored by following the CO stretching band at 1975 cm⁻¹ by IR. The volume of the solvent was reduced under vacuum and n-hexane added to induce crystallization (yield 0.078 g, 17%). The sample was not pure and did not give satisfactory microanalysis. The EI mass spectrum of the complex showed a cluster corresponding to the parent ion W(C₆H₅CH₂N(CH₃)₂)(CO)₅ centered at m/e 459 and the isotope pattern matched that predicted from theory. Clusters corresponding to sequential loss of CO groups were observed at m/e of 431 $[W(C_6H_5CH_2N(CH_3)_2)(CO)_4]$, 403 $[W(C_6H_5CH_2N(CH_3)_2(CO)_3]$ and 375 [W(C₆H₅CH₂N(CH₃)₂)(CO)₂]. Clusters at m/e 345, 317 and 135 were assigned to W(C₆H₅CH₂N)(CO)₂, W(C₆H₅CH₂N)(CO) and [C₆H₅CH₂N(CH₃)₂ + H⁺], respectively. Clusters corresponding to W(CO)₆, W(CO)₅, W(CO)₄, W(CO)₃, W(CO)₂, W(CO) and W were also observed. The W(CO)₆ was most likely present as an impurity in the sample. ¹H NMR (CDCl₃): 2.78 (s, 6H, CH₃), 4.22 (s, 2H, CH₂), 7.25–7.34 (*m*, 5H, aromatic). ¹³C NMR: 55.3 (CH₃), 73.6 (CH₂), 128.5 (aromatic C₃, C₅), 129.0 (aromatic C₄), 132.0 (aromatic, C₂, C₆), 191, 199, 202 (carbonyl). IR (KBr, cm⁻¹): 3425 (m), 1952 (m), 1060 (w), 932 (m), 853 (m) 774 (m), 592 (s).

Crystal data

$[W(C_9H_{13}N)(CO)_5]$	Mo $K\alpha$ radiation	
$M_r = 459.10$	Cell parameters from 4675	
Orthorhombic, Pbca	reflections	
a = 13.7829 (11) Å	$\theta = 2.5 - 28.1^{\circ}$	
b = 12.5247 (10) Å	$\mu = 7.33 \text{ mm}^{-1}$	
c = 18.2985 (14) Å	T = 150 (2) K	
$V = 3158.8 \text{ (4) Å}^3$	Plate, yellow	
Z = 8	$0.28 \times 0.20 \times 0.05 \text{ mm}$	
$D_{\rm w} = 1.931 \; {\rm Mg \; m^{-3}}$		

Data collection

Bruker SMART 1000 CCD	3870 independent reflections
diffractometer	2534 reflections with $I > 2\sigma(I)$
ω rotation with narrow-frame scans	$R_{\rm int} = 0.059$
Absorption correction: multi-scan	$\theta_{\rm max} = 29.0^{\circ}$
(SADABS; Sheldrick, 2003)	$h = -13 \rightarrow 18$
$T_{\min} = 0.233, T_{\max} = 0.711$	$k = -16 \rightarrow 16$
18147 measured reflections	$l = -24 \rightarrow 22$

Refinement

Refinement on F^2	$w = 1/[\sigma^2(F_0^2) + (0.0125P)^2]$
$R[F^2 > 2\sigma(F^2)] = 0.033$	+ 14.4005P]
$wR(F^2) = 0.074$	where $P = (F_0^2 + 2F_c^2)/3$
S = 1.03	$(\Delta/\sigma)_{\text{max}} = 0.001$
3870 reflections	$\Delta \rho_{\text{max}} = 1.10 \text{ e Å}^{-3}$
192 parameters	$\Delta \rho_{\min} = -0.85 \text{ e Å}^{-3}$
H-atom parameters constrained	

Table 1 Selected geometric parameters (Å, °).

W1-N1	2.371 (5)	O11-C11	1.144 (8)
W1-C10	1.964 (7)	O12-C12	1.152 (8)
W1-C11	2.041 (6)	O13-C13	1.156 (7)
W1-C12	2.034 (6)	O14-C14	1.142 (7)
W1-C13	2.033 (6)	N1-C1	1.492 (9)
W1-C14	2.048 (6)	N1-C2	1.496 (9)
O10-C10	1.157 (9)	N1-C3	1.514 (8)
N1-W1-C10	176.8 (2)	C13-W1-C14	172.6 (3)
N1-W1-C11	93.9 (2)	W1-N1-C1	110.0 (4)
N1-W1-C12	89.8 (2)	W1-N1-C2	111.7 (4)
N1-W1-C13	91.5 (2)	W1-N1-C3	109.1 (4)
N1-W1-C14	95.6 (2)	C1-N1-C2	107.4 (5)
C10-W1-C11	88.4 (3)	C1-N1-C3	109.3 (5)
C10-W1-C12	88.0 (3)	C2-N1-C3	109.3 (5)
C10-W1-C13	86.3 (3)	N1-C3-C4	115.8 (6)
C10-W1-C14	86.7 (3)	W1-C10-O10	177.2 (6)
C11-W1-C12	174.8 (3)	W1-C11-O11	176.4 (6)
C11-W1-C13	90.5 (2)	W1-C12-O12	174.0 (6)
C11-W1-C14	86.8 (2)	W1-C13-O13	173.9 (6)
C12-W1-C13	93.1 (3)	W1-C14-O14	174.5 (5)
C12-W1-C14	89.1 (3)		

H atoms bonded to C atoms were inserted at calculated positions and refined using a riding model. The constrained C—H distances were 0.95, 0.98 and 0.99 Å for aryl, methyl, and methylene H atoms, respectively. The H atoms of methylene and aryl groups were refined with $U_{\rm iso}({\rm H})=1.2U_{\rm eq}({\rm C})$ and those of the methyl groups with $U_{\rm iso}({\rm H})=1.5U_{\rm eq}({\rm C})$. The highest residual electron-density peak is 0.88 Å from the W atom.

Data collection: *SMART* (Bruker, 1998); cell refinement: *SAINT* (Bruker, 1998); data reduction: *SAINT*; program(s) used to solve structure: *SHELXTL* (Sheldrick, 2001); program(s) used to refine structure: *SHELXTL*; molecular graphics: *SHELXTL*; software used to prepare material for publication: *SHELXTL* and local programs.

metal-organic papers

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